

SUBSTITUTE FORM PTO-1449 (MODIFIED)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. SSIT-114		SERIAL NO. 10/711,649	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary)				APPLICANT Kawamura et al.		FILING DATE 09/29/2004	
				GROUP 1756			

U.S. PATENT DOCUMENTS													
EXAMINER INITIAL		PATENT NUMBER							ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
MDH	A.A	6	5	9	6	0	9	3	07/22/2003	DeYoung et al.	134	36	09/13/2001
	A.B												
	A.C												
	A.D												
	A.E												
	A.F												
	A.G												
	A.H												
	A.I												
	A.J												
	A.K												

FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)
MDH	A.L	JP 4-284648	10/09/1992	JP	H01L	21/68	Abstract Only
	A.M	JP 62-111442	05/22/1987	JP	H01L	21/68	Abstract Only
↓	A.N	JP 63-256326	10/24/1988	JP	B23Q	3/08	Abstract Only
	A.O						
	A.P						
	A.Q						

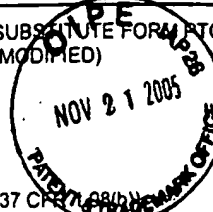
  

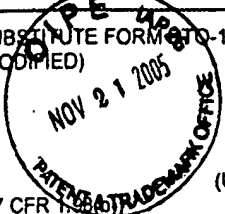
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)		
MDH	A.R	Cotte et al., Process and Apparatus for Contacting a Precision Surface with Liquid or Supercritical Carbon Dioxide. US 2003/0196679 A1; Publication Date 10/23/2003; Filing Date 04/18/2002; U.S. Class 134/1
	A.S	
	A.T	

EXAMINER 	DATE CONSIDERED 3/3/06
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MDH	A.A	5	6	1	8	7	5	1	04/08/1997	Golden et al.	438	392	05/23/1996
↓	A.B	6	9	2	6	7	9	8	08/09/2005	Biberger et al.	156	345.31	03/06/2003
	A.C												
	A.D												
	A.E												
	A.F												
	A.G												
	A.H												
	A.I												
	A.J												
	A.K												
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		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)						
MDH	A.L	WO 01/33613 A2	05/10/2001	PCT	H01L	21/00							
↓	A.M	WO 02/15251 A1	02/21/2002	PCT	H01L	21/311							
	A.N												
	A.O												
	A.P												
	A.Q												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDH	A.R	Jones et al., <u>HF Etchant Solutions In Supercritical Carbon Dioxide for "Dry" Etch Processing of Microelectronic Devices</u> , Chem Mater., Vol. 15, 2003, pp. 2867-2869											
↓	A.S	Gangopadhyay et al., <u>Supercritical CO<sub>2</sub> Treatments for Semiconductor Applications</u> , Mat. Res. Soc. Symp. Proc., Vol. 812, 2004, pp. F4.6.1-F4.6.6											
↓	A.T	DeYoung et al., <u>Methods and Compositions for Etch Cleaning Microelectronic Substrates in Carbon Dioxide</u> , US 2004/0045588 A1; Publication Date 03/11/2004; Filed 09/10/2003; U.S. Class 134/26											
EXAMINER <i>Monica D. Davis</i>				DATE CONSIDERED <i>3/3/06</i>									
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SUBSTITUTE FORM PTO-1449 (MODIFIED)  (37 CFR 1.880)	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. SSIT-114	SERIAL NO. 10/711,649
	INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary)		APPLICANT Kawamura et al.	
			FILING DATE September 29, 2004	GROUP 1756

## U.S. PATENT DOCUMENTS

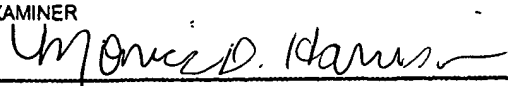
EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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	B.B						
	B.C						
	B.D						
	B.E						
	B.F						
	B.G						
	B.H						
	B.I						
	B.J						
	B.K						

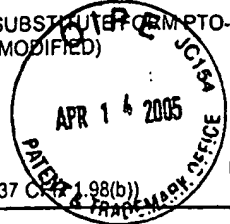
## FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS

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	B.L					
	B.M					
	B.N					
	B.O					
	B.P					
	B.Q					

## OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)

MDH	B.R	European Patent Office, <u>International Search Report</u> , PCT/US2005/013885, 10/24/2005, 4 pp.
	B.S	
	B.T	

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(37 C.F.R. 1.98(b)) 							
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL	PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
MDH	A.A. 2 4 3 9 6 8 9	04/13/1948	Hyde	117	124	06/11/1943	
	A.B. 2 6 1 7 7 1 9	11/11/1952	C. R. Stewart	23	312	12/29/1950	
	A.C. 2 6 2 5 8 8 6	01/20/1953	Browne	103	150	08/21/1947	
	A.D. 3 7 4 4 6 6 0	07/10/1973	Gaines et al.	220	10	12/30/1970	
	A.E. 3 8 9 0 1 7 6	06/17/1975	Bolon	156	2	12/17/1973	
	A.F. 3 9 0 0 5 5 1	08/19/1975	Bardocelli et al.	423	9	03/02/1972	
	A.G. 3 9 6 8 8 8 5	07/13/1976	Hassan et al.	214	1 BC	08/27/1974	
	A.H. 4 0 2 9 5 1 7	06/14/1977	Rand	134	11	03/01/1976	
	A.I. 4 0 9 1 6 4 3	05/30/1978	Zucchini	68	18 C	02/17/1977	
	A.J. 4 2 1 9 3 3 3	08/26/1980	Harris	8	137	07/03/1978	
✓	A.K. 4 2 4 5 1 5 4	01/13/1981	Uehara et al.	250	227	06/28/1978	
FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
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	A.L.						
	A.M.						
	A.N.						
	A.O.						
	A.P.						
	A.Q.						
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)							
MDH	A.R.	J. B. Rubin et al., <u>A Comparison of Chilled DI Water/Ozone and CO<sub>2</sub>-based Supercritical Fluids as Replacements for Photoresist-Stripping Solvents</u> , IEEE/CPMT Int'l Electronics Manufacturing Technology Symposium, pp. 308-314, 1998.					
	A.S.	<u>Los Alamos National Laboratory</u> , Solid State Technology, pp. S10 & S14, October 1998.					
✓	A.T.	<u>Supercritical Carbon Dioxide Resist Remover, SCORR, the Path to Least Photoresistance</u> , Los Alamos National Laboratory, 1998.					
EXAMINER  Mance P. Hamer				DATE CONSIDERED  3/3/06			
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U.S. PATENT DOCUMENTS													
EXAMINER INITIAL		PATENT NUMBER						ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
MDI	B.A	4	3	4	1	5	9	2	07/27/1982	Shortes et al.	156	643	08/04/1975
	B.B	4	3	4	9	4	1	5	08/14/1982	DeFilippi et al.	204	14	08/28/1979
	B.C	4	3	5	5	9	3	7	10/26/1982	Mack et al.	414	217	12/24/1980
	B.D	4	3	6	7	1	4	0	01/04/1983	Wilson	210	110	10/30/1980
	B.E	4	4	0	6	5	9	6	09/27/1983	Budde	417	393	07/27/1981
	B.F	4	4	2	2	6	5	1	12/27/1983	Platts	277	206 R	12/27/1978
	B.G	4	4	7	4	1	9	9	10/02/1984	Blaudszun	134	105	11/09/1982
	B.H	4	4	7	5	9	9	3	10/09/1984	Blander et al.	204	64	08/15/1983
	B.I	4	5	2	2	7	8	8	06/11/1985	Sitek et al.	422	78	03/05/1982
	B.J	4	5	4	9	4	6	7	10/29/1985	Wilden et al.	91	307	08/03/1983
↓	B.K	4	5	9	2	3	0	6	06/03/1986	Gallego	118	719	11/30/1984
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	B.M												
	B.N												
	B.O												
	B.P												
	B.Q												
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MDI	B.R	Z. Guan et al., <u>Fluorocarbon-Based Heterophase Polymeric Materials. I. Block Copolymer Surfactants for Carbon Dioxide Applications</u> , <u>Macromolecules</u> , Vol. 27, pp 5527-5532, 1994.											
↓	B.S	<u>International Journal of Environmentally Conscious Design &amp; Manufacturing</u> , Vol. 2, No. 1, pp. 83, 1993.											
↓	B.T	Matson and Smith, <u>Supercritical Fluids</u> , <u>Journal of the American Ceramic Society</u> , Vol. 72, No. 6, pp. 872-874.											
EXAMINER <i>Monica D. Hansen</i>									DATE CONSIDERED <i>3/3/06</i>				
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U.S. PATENT DOCUMENTS							
EXAMINER INITIAL	PATENT NUMBER	PATENT NUMBER	PATENT NUMBER	PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS
MDH	C.A	4	6	0	1	1	8
	C.B	4	6	2	6	5	0
	C.C	4	6	7	0	1	2
	C.D	4	6	8	2	9	3
	C.E	4	6	9	3	7	7
	C.F	4	7	4	9	4	4
	C.G	4	7	7	8	3	5
	C.H	4	7	8	8	0	4
	C.I	4	7	8	9	0	7
	C.J	4	8	2	3	9	7
V	C.K	4	8	2	5	8	0
FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
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	C.M						
	C.N						
	C.O						
	C.P						
	C.Q						
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)							
MDH	C.R	D. H. Ziger et al., <u>Compressed Fluid Technology: Application to RIE Developed Resists</u> , AIChE Journal, Vol. 33, No. 10, pp. 1585-1591, October 1987.					
I	C.S	Kirk-Othmer, <u>Alcohol Fuels to Toxicology</u> , Encyclopedia of Chemical Terminology, 3rd ed., Supplement Volume, New York: John Wiley & Sons, pp. 872-893, 1984.					
V	C.T	<u>Cleaning with Supercritical CO<sub>2</sub></u> , NASA Tech Briefs, MFS-29611, Marshall Space Flight Center, Alabama, March 1979.					
EXAMINER  Umner D. Hamer					DATE CONSIDERED  3/3/06		
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EXAMINER INITIAL		PATENT NUMBER						ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
MDH	D.A	4	8	2	7	8	6	7	05/09/1989	Takei et al.	118	64	11/21/1986
	D.B	4	8	3	8	4	7	6	06/13/1989	Rahn	228	180.1	11/12/1987
	D.C	4	8	6	5	0	6	1	09/12/1989	Fowler et al.	134	108	07/22/1983
	D.D	4	8	7	7	5	3	0	10/31/1989	Moses	210	511	02/29/1988
	D.E	4	8	7	9	0	0	4	11/07/1989	Oesch et al.	203	89	05/04/1988
	D.F	4	8	7	9	4	3	1	11/07/1989	Bertoncini	435	311	03/09/1989
	D.G	4	9	1	7	5	5	6	04/17/1990	Stark et al.	414	217	05/26/1989
	D.H	4	9	2	3	8	2	8	05/08/1990	Gluck et al.	437	225	08/07/1989
	D.I	4	9	2	4	8	9	2	05/15/1990	Kiba et al.	134	123	07/28/1988
	D.J	4	9	2	5	7	9	0	05/15/1990	Blanch et al.	435	52	08/30/1985
✓	D.K	4	9	3	3	4	0	4	06/12/1990	Beckman et al.	526	207	11/22/1988
FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS													
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	D.L												
	D.M												
	D.N												
	D.O												
	D.P												
	D.Q												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDH	D.R	N. Basta, <u>Supercritical Fluids: Still Seeking Acceptance</u> , Chemical Engineering Vol. 92, No. 3, pp. 14, February 24, 1985.											
↓	D.S	D. Takahashi, <u>Los Alamos Lab Finds Way to Cut Chip Toxic Waste</u> , Wall Street Journal, June 22, 1998.											
↓	D.T	<u>Supercritical CO<sub>2</sub> Process Offers Less Mess from Semiconductor Plants</u> , Chemical Engineering Magazine, pp. 27 & 29, July 1988.											
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MDH	E.A	4	9	4	4	8	3	7	07/31/1990	Nishikawa et al.	156	646	02/28/1989
	E.B	4	9	5	1	6	0	1	08/28/1990	Maydan et al.	118	719	06/23/1989
	E.C	4	9	6	0	1	4	0	10/02/1990	Ishijima et al.	134	31	11/27/1985
	E.D	4	9	8	3	2	2	3	01/08/1991	Gessner	134	25.4	10/24/1989
	E.E	5	0	1	1	5	4	2	04/30/1991	Weil	134	38	07/21/1988
	E.F	5	0	1	3	3	6	6	05/07/1991	Jackson et al.	134	1	12/07/1988
	E.G	5	0	4	4	8	7	1	09/03/1991	Davis et al.	414	786	01/13/1988
	E.H	5	0	6	2	7	7	0	11/05/1991	Story et al.	417	46	08/11/1989
	E.I	5	0	6	8	0	4	0	11/26/1991	Jackson	210	748	04/03/1989
	E.J	5	0	7	1	4	8	5	12/10/1991	Matthews et al.	134	2	09/11/1990
✓	E.K	5	1	0	5	5	5	6	04/21/1992	Kurokawa et al.	34	12	08/09/1988
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	E.P												
	E.Q												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDH	E.R	Y. P. Sun, <u>Preparation of Polymer Protected Semiconductor Nanoparticles Through the Rapid Expansion of Supercritical Fluid Solution</u> , Chemical Physics Letters, pp. 585-588, May 22, 1998.											
↓	E.S	K. Jackson et al., <u>Surfactants and Micromulsions in Supercritical Fluids</u> , Supercritical Fluid Cleaning, Noyes Publications, Westwood, NJ, pp. 87-120, Spring 1998.											
↓	E.T	M. Kryszcwski, <u>Production of Metal and Semiconductor Nanoparticles in Polymer Systems</u> , Polimery, pp. 65-73, February 1998.											
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MDH	F.A	5	1	4	3	1	0	3	09/01/1992	Basso et al.	134	98.1	01/04/1991
	F.B	5	1	5	8	7	0	4	10/27/1992	Fulton et al.	252	309	07/25/1990
	F.C	5	1	6	7	7	1	6	12/01/1992	Boitnott et al.	118	719	09/28/1990
	F.D	5	1	6	9	2	9	6	12/08/1992	Wilden	417	395	03/10/1989
	F.E	5	1	6	9	4	0	8	12/08/1992	Biggerstaff et al.	29	25.01	01/26/1990
	F.F	5	1	7	4	9	1	7	12/29/1992	Monzyk	252	60	07/19/1991
	F.G	5	1	8	5	0	5	8	02/09/1993	Cathey, Jr.	156	656	01/29/1991
	F.H	5	1	8	5	2	9	6	02/09/1993	Morita et al.	437	229	04/24/1991
	F.I	5	1	8	6	5	9	4	02/16/1993	Toshima et al.	414	217	04/19/1990
	F.J	5	1	8	6	7	1	8	02/16/1993	Tepman et al.	29	25.01	04/15/1991
	F.K	5	1	8	8	5	1	5	02/23/1993	Horn	417	63	06/03/1991
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	F.M												
	F.N												
	F.O												
	F.P												
	F.Q												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDH	F.R	G. L. Bakker et al., <u>Surface Cleaning and Carbonaceous Film Removal Using High Pressure, High Temperature Water, and Water/CO<sub>2</sub> Mixtures</u> , J Electrochem Soc., Vol. 145, No. 1, pp. 284-291, January 1998.											
	F.S	C. K. Ober et al., <u>Imaging Polymers with Supercritical Carbon Dioxide</u> , Advanced Materials, Vol. 9, No. 13, pp. 1039-1043, November 3, 1997.											
	F.T	E. M. Russick et al., <u>Supercritical Carbon Dioxide Extraction of Solvent from Micro-Machined Structures</u> , Supercritical Fluids Extraction and Pollution Prevention, ACS Symposium Series, Vol. 670, pp. 255-269, October 21, 1997.											
EXAMINER <i>Monica D. Harris</i>										DATE CONSIDERED <i>3/3/06</i>			
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT  (Use several sheets if necessary)  (37 CFR 1.98(b))				APPLICANT Kawamura et al.									
				FILING DATE September 29, 2004		GROUP 1756							
U.S. PATENT DOCUMENTS													
EXAMINER INITIAL		PATENT NUMBER			ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE				
MDH	G.A	5	1	9	0	3	7	3	03/02/1993	Dickson et al.	366	146	12/24/1991
	G.B	5	1	9	1	9	9	3	03/09/1993	Wanger et al.	220	333	02/24/1992
	G.C	5	1	9	3	5	6	0	03/16/1993	Tanaka et al.	134	56 R	06/24/1991
	G.D	5	1	9	5	8	7	8	03/23/1993	Sahlavo et al. *	417	393	05/20/1991
	G.E	5	1	9	6	1	3	4	03/23/1993	Jackson	252	103	08/17/1992
	G.F	5	2	0	1	9	6	0	04/13/1993	Starov	134	11	02/26/1992
	G.G	5	2	1	3	4	8	5	05/25/1993	Wilden	417	393	11/19/1991
	G.H	5	2	1	3	6	1	9	05/25/1993	Jackson et al.	134	1	11/30/1989
	G.I	5	2	1	5	5	9	2	06/01/1993	Jackson	134	1	01/22/1991
	G.J	5	2	1	7	0	4	3	06/08/1993	Novakovi *	137	460	02/24/1992
↓	G.K	5	2	2	1	0	1	9	06/22/1993	Pechacek et al.	220	315	11/07/1991
FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS													
		DOCUMENT NUMBER			PUBLICATION DATE		COUNTRY OR PATENT OFFICE		CLASS	SUBCLASS	TRANSLATION (YES/NO)		
	G.L												
	G.M												
	G.N												
	G.O												
	G.P												
	G.Q												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDH	G.R	N. Dahmen et al., <u>Supercritical Fluid Extraction of Grinding and Metal Cutting Waste Contaminated with Oils</u> , Supercritical Fluids - Extraction and Pollution Prevention, ACS Symposium Series, Vol. 670, pp. 270-279, October 21, 1997.											
↓	G.S	C. M. Wal, <u>Supercritical Fluid Extraction: Metals as Complexes</u> , Journal of Chromatography A, Vol. 785, pp. 369-383, October 17, 1997.											
↓	G.T	C. Xu et al., <u>Submicron-Sized Spherical Yttrium Oxide Based Phosphors Prepared by Supercritical CO<sub>2</sub>-Assisted Nerosolization and Pyrolysis</u> , Appl. Phys. Lett., Vol. 71, No. 22, pp. 1643-1645, September 22, 1997.											
EXAMINER <i>Unver D. Dawid</i>						DATE CONSIDERED <i>3/3/06</i>							
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT				APPLICANT Kawamura et al.			
(37 CFR 1.98(b)) (Use several sheets if necessary)				FILING DATE September 29, 2004		GROUP 1756	

U.S. PATENT DOCUMENTS													
EXAMINER INITIAL		PATENT NUMBER							ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
MDH	H.A	5	2	2	2	8	7	6	06/29/1993	Budde	417	393	09/30/1991
	H.B	5	2	2	4	5	0	4	07/06/1993	Thompson et al.	134	155	07/30/1992
	H.C	5	2	2	5	1	7	3	07/06/1993	Wai	423	2	10/25/1991
	H.D	5	2	3	6	6	0	2	08/17/1996	Jackson	210	748	01/28/1991
	H.E	5	2	3	6	6	6	9	08/17/1993	Simmons et al.	422	113	05/08/1992
	H.F	5	2	3	7	8	2	4	08/24/1993	Pawliszyn	62	51.1	02/16/1990
	H.G	5	2	3	8	6	7	1	08/24/1993	Matson et al.	423	397	11/22/1988
	H.H	5	2	4	0	3	9	0	08/31/1993	Kvinge et al.	417	393	03/27/1992
	H.I	5	2	4	3	8	2	1	09/14/1993	Schuck et al.	62	50.6	06/24/1991
	H.J	5	2	4	6	5	0	0	09/21/1993	Samata et al.	118	719	09/01/1992
✓	H.K	5	2	5	0	0	7	8	10/05/1993	Saus et al.	8	475	05/12/1992

FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
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	H.L						
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	H.O						
	H.P						
	H.Q						

OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)		
MDH	H.R	Y. Tomloka et al., <u>Decomposition of Tetramethylammonium (TMA) in a Positive Photo-resist Developer by Supercritical Water</u> , Abstracts of Papers 214th ACS Natl Meeting, American Chemical Society, Abstract No. 108, September 7, 1997.
↓	H.S	H. Klein et al., <u>Cyclic Organic Carbonates Serve as Solvents and Reactive Diluents</u> , Coatings World, pp. 38-40, May 1997.
↓	H.T	J. Böhler et al., <u>Linear Array of Complementary Metal Oxide Semiconductor Double-Pass Metal Micro-mirrors</u> , Opt. Eng. Vol. 36, No. 5, pp. 1391-1398, May 1997.

EXAMINER <i>Monica D. Kamm</i>	DATE CONSIDERED <i>3/3/06</i>
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U.S. PATENT DOCUMENTS													
EXAMINER INITIAL		PATENT NUMBER						ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
MDH	I.A.	5	2	5	1	7	7	6	10/12/1993	Morgan, Jr. et al.	220	360	08/12/1991
	I.B.	5	2	6	1	9	6	5	11/16/1993	Moslehi	134	1	08/28/1992
	I.C.	5	2	6	6	2	0	5	113-1003	Fulton et al.	210	639	07/01/1992
	I.D.	5	2	6	7	4	5	5	12/07/1993	Deweese et al.	68	5 C	07/13/1992
	I.E.	5	2	6	9	8	1	5	12/14/1993	Schlenker et al.	8	475	11/13/1992
	I.F.	5	2	6	9	8	5	0	12/14/1993	Jackson	134	2	08/27/1990
	I.G.	5	2	7	4	1	2	9	12/28/1993	Natale et al.	549	349	06/12/1991
	I.H.	5	2	8	0	6	9	3	01/25/1994	Heudecker	53	306	10/07/1992
	I.I.	5	2	8	5	3	5	2	02/08/1994	Pastore et al.	361	707	07/15/1992
	I.J.	5	2	8	8	3	3	3	02/22/1994	Tanaka et al.	134	31	07/29/1992
	I.K.	5	2	9	0	3	6	1	03/01/1994	Hayashida et al.	134	2	01/23/1992
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		DOCUMENT NUMBER						PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)	
	I.L.												
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	I.O.												
	I.P.												
	I.Q.												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDH	I.R.	M. H. Jo et al., <u>Evaluation of SiO<sub>2</sub> Aerogel Thin Film with Ultra Low Dielectric Constant as an Intermetal Dielectric</u> , Microelectronic Engineering, Vol. 33, pp. 343-348, January 1997.											
	I.S.	J. B. McClain et al., <u>Design of Nonionic Surfactants for Supercritical Carbon Dioxide</u> , Science, Vol. 274, pp. 2049-2052, December 20, 1996.											
	I.T.	L. Znaidi et al., <u>Batch and Semi-Continuous Synthesis of Magnesium Oxide Powders from Hydrolysis and Supercritical Treatment of Mg(OCH<sub>3</sub>)<sub>2</sub></u> , Materials Research Bulletin, Vol. 31, No. 12, pp. 1527-1535, December 1996.											
EXAMINER <i>Yunus D. Hameed</i>									DATE CONSIDERED <i>3/3/06</i>				
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U.S. PATENT DOCUMENTS													
EXAMINER INITIAL		PATENT NUMBER							ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
MDH	J.A	5	2	9	4	2	6	1	03/15/1994	McDermott et al.	134	7	11/02/1992
	J.B	5	2	9	8	0	3	2	03/29/1994	Schlenker et al.	8	475	08/08/1992
	J.C	5	3	0	4	5	1	5	04/19/1994	Morita et al.	437	231	08/07/1992
	J.D	5	3	0	6	3	5	0	04/26/1994	Hoy et al.	134	22.14	04/27/1992
	J.E	5	3	1	2	8	8	2	05/17/1994	DeSimone et al.	526	201	07/30/1993
	J.F	5	3	1	3	9	6	5	05/24/1994	Palen	134	61	06/01/1992
	J.G	5	3	1	4	5	7	4	05/24/1994	Takahashi	156	646	06/25/1993
	J.H	5	3	1	6	5	9	1	05/31/1994	Chao et al.	134	34	08/10/1992
	J.I	5	3	2	0	7	4	2	06/14/1994	Fletcher et al.	208	89	10/19/1992
	J.J	5	3	2	8	7	2	2	07/12/1994	Ghanayem et al.	427	250	11/06/1992
✓	J.K	5	3	3	4	3	3	2	08/02/1994	Lee	252	548	07/09/1992
FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS													
		DOCUMENT NUMBER		PUBLICATION DATE		COUNTRY OR PATENT OFFICE		CLASS	SUBCLASS	TRANSLATION (YES/NO)			
	J.L												
	J.M												
	J.N												
	J.O												
	J.P												
	J.Q												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDH	J.R	M. E. Tadros, <u>Synthesis of Titanium Dioxide Particles in Supercritical CO<sub>2</sub></u> , J. Supercritical Fluids, Vol. 9, pp. 172-176, September 1996.											
	J.S	V. G. Courtecuisse et al., <u>Kinetics of the Titanium Isopropoxide Decomposition in Supercritical Isopropyl Alcohol</u> , Ind. Eng. Chem. Res., Vol. 35, No. 8, pp. 2539-2545, August 1996.											
✓	J.T	A. Gabor et al., <u>Block and Random Copolymer Resists Designed for 193 nm Lithography and Environmentally Friendly Supercritical CO<sub>2</sub> Development</u> , SPIE, Vol. 2724, pp. 410-417, June 1996.											
EXAMINER <i>Monica D. Davis</i>										DATE CONSIDERED <i>3/3/06</i>			
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EXAMINER INITIAL		PATENT NUMBER							ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
MDH	K.A	5	3	3	4	4	9	3	08/02/1994	Fujita et al.	430	463	09/29/1993
	K.B	5	3	3	7	4	4	6	08/18/1994	Smith et al.	15	21.1	10/27/1992
	K.C	5	3	3	9	8	4	4	08/23/1994	Stanford, Jr. et al.	134	107	09/07/1993
	K.D	5	3	5	2	3	2	7	10/04/1994	Witowski	156	646	07/10/1992
	K.E	5	3	5	5	9	0	1	10/18/1994	Mielnik et al.	134	105	10/27/1992
	K.F	5	3	5	6	5	3	8	10/18/1994	Wai et al.	210	634	10/21/1991
	K.G	5	3	6	4	4	9	7	11/15/1994	Chau et al.	156	645	08/04/1993
	K.H	5	3	6	8	1	7	1	11/29/1994	Jackson	134	147	07/20/1992
	K.I	5	3	7	0	7	4	0	12/06/1994	Chao et al.	134	1	10/01/1993
	K.J	5	3	7	0	7	4	1	12/06/1994	Bergman	134	3	11/18/1992
✓	K.K	5	3	7	0	7	4	2	12/06/1994	Mitchell et al.	134	10	07/13/1992
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	K.L												
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	K.N												
	K.O												
	K.P												
	K.Q												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDH	K.R	G. L. Schimek et al., <u>Supercritical Ammonia Synthesis and Characterization of Four New Alkali Metal Silver Antimony Sulfides</u> , J. Solid State Chemistry, Vol. 123, pp. 277-284, May 1996.											
✓	K.S	P. Gallagher-Wetmore et al., <u>Supercritical Fluid Processing: Opportunities for New Resist Materials and Processes</u> , SPIE, Vol. 2725, pp. 289-299, April 1996.											
✓	K.T	K. I. Papathomas et al., <u>Debonding of Photoresists by Organic Solvents</u> , J. Applied Polymer Science, Vol. 59, pp. 2029-2037, March 28, 1996											
EXAMINER <i>Monica D. Harris</i>										DATE CONSIDERED <i>3/3/06</i>			
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U.S. PATENT DOCUMENTS													
EXAMINER INITIAL		PATENT NUMBER							ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
MDH	L.A.	5	3	7	7	7	0	5	01/03/1995	Smith, Jr. et al.	134	95.3	09/16/1993
	L.B.	5	4	0	1	3	2	2	03/28/1995	Marshall	134	13	06/30/1992
	L.C.	5	4	0	3	6	2	1	04/04/1995	Jackson et al.	427	255.1	10/01/1993
	L.D.	5	4	0	3	6	6	5	04/04/1995	Alley et al.	428	447	06/18/1993
	L.E.	5	4	0	4	8	9	4	04/11/1995	Shiraiwa	134	66	05/18/1993
	L.F.	5	4	1	2	9	5	8	05/09/1995	Iliff et al.	68	5 C	12/06/1993
	L.G.	5	4	1	7	7	6	8	05/23/1995	Smith, Jr. et al.	134	10	12/14/1993
	L.H.	5	4	3	3	3	3	4	07/18/1995	Reneau	220	319	09/08/1993
	L.I.	5	4	4	7	2	9	4	09/05/1995	Sakata et al.	266	257	01/21/1994
	L.J.	5	4	5	6	7	5	9	10/10/1995	Stanford, Jr. et al.	134	1	08/01/1994
	L.K.	5	4	7	0	3	9	3	11/28/1995	Fukazawa	134	3	07/08/1994

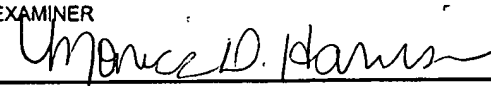
  

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	L.N.						
	L.O.						
	L.P.						
	L.Q.						

OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)		
MDH	L.R.	J. J. Watkins et al., <u>Polymer/Metal Nanocomposite Synthesis in Supercritical CO<sub>2</sub></u> , Chemistry of Materials, Vol. 7, No. 11, pp. 1991-1994, November 1995.
	L.S.	E. F. Gloyna et al., <u>Supercritical Water Oxidation Research and Development Update</u> , Environmental Progress, Vol. 14, No. 3, pp. 182-192, August 1995.
	L.T.	P. Gallagher-Wetmore et al., <u>Supercritical Fluid Processing: A New Dry Technique for Photoresist Developing</u> , SPIE, Vol. 2438, pp. 694-708, June 1995.

EXAMINER 	DATE CONSIDERED 3/3/06
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MDH	M.A 5 4 7 4 8 1 2	12/12/1995	Truckenmuller et al.	427	430.1	03/07/1995					
	M.B 5 4 8 2 5 6 4	01/09/1996	Douglas et al.	134	18	06/21/1994					
	M.C 5 4 8 6 2 1 2	01/23/1996	Mitchell et al.	8	142	03/15/1995					
	M.D 5 4 9 4 5 2 6	02/27/1996	Paranjpe	134	1	05/04/1995					
	M.E 5 5 0 0 0 8 1	03/19/1996	Bergman	156	646.1	12/05/1994					
	M.F 5 5 0 1 7 6 1	03/26/1996	Evans et al.	156	344	10/18/1994					
	M.G 5 5 0 3 1 7 6	04/02/1996	Dummire et al.	137	15	10/25/1994					
	M.H 5 5 0 5 2 1 9	04/09/1996	Lansberry et al.	134	105	11/23/1994					
	M.I 5 5 0 9 4 3 1	04/23/1996	Smith, Jr. et al.	134	95.1	11/14/1994					
	M.J 5 5 1 4 2 2 0	05/07/1996	Wetmore et al.	134	22.18	12/09/1992					
✓	M.K 5 5 2 2 9 3 8	08/04/1996	O'Brien	134	1	08/08/1994					

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M.L							
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M.O							
M.P							
M.Q							

OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)		
MDH	M.R	A. H. Gabor et al., <u>Silicon-Containing Block Copolymer Resist Materials</u> , Microelectronics Technology - Polymers for Advanced Imaging and Packaging, ACS Symposium Series, Vol. 615, pp. 281-298, April 1995.
↓	M.S	P. C. Tsiartas et al., <u>Effect of Molecular Weight Distribution on the Dissolution Properties of Novolac Blends</u> , SPIE, Vol. 2438, pp. 264-271, June 1995.
✓	M.T	R. D. Allen et al., <u>Performance Properties of Near-Monodisperse Novolak Resins</u> , SPIE, Vol. 2438, pp. 250-260, June 1995.

EXAMINER <i>Umance D. Hansen</i>	DATE CONSIDERED <i>3/3/06</i>
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MDH	N.A	5	5	2	6	8	3	4	06/18/1996	Mielnik et al.	134	105	08/17/1994
	N.B	5	5	3	3	5	3	8	07/09/1996	Marshall	134	104.4	12/01/1994
	N.C	5	5	4	7	7	7	4	08/20/1996	Gimzewski et al.	428	694	09/01/1993
	N.D	5	5	5	0	2	1	1	08/27/1996	DeCrosta et al.	528	489	12/17/1992
	N.E	5	5	7	1	3	3	0	11/05/1996	Kyogoku	118	719	11/12/1993
	N.F	5	5	8	0	8	4	6	12/03/1996	Hayashida et al.	510	175	01/09/1995
	N.G	5	5	8	9	0	8	2	12/31/1996	Lin et al.	216	2	06/07/1995
	N.H	5	5	8	9	1	0	5	12/31/1996	DeSimone et al.	252	351	05/18/1995
	N.I	5	5	8	9	2	2	4	12/31/1996	Tepman et al.	427	248.1	09/22/1994
	N.J	5	6	2	1	9	8	2	04/22/1997	Yamashita et al.	34	203	10/27/1994
	N.K	5	6	2	9	9	1	8	05/13/1997	Ho et al.	369	112	01/20/1995
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	N.N												
	N.O												
	N.P												
	N.Q												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDH	N.R	P. T. Wood et al., <u>Synthesis of New Channeled Structures in Supercritical Amines...</u> , Inorg. Chem., Vol. 33, pp. 1556-1558, 1994.											
	N.S	J. B. Jerome et al., <u>Synthesis of New Low-Dimensional Quaternary Compounds...</u> , Inorg. Chem., Vol. 33, pp. 1733-1734, 1994.											
	N.T	J. McHardy et al., <u>Progress in Supercritical CO<sub>2</sub> Cleaning</u> , SAMPE Jour, Vol. 29, No. 5, pp. 20-27, September 1993.											
EXAMINER							DATE CONSIDERED						
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EXAMINER Initial if citation considered, whether or not in conformance. Draw line through citation only if not in conformance and not considered. Include a copy of this form with next communication to Applicant.													

SUBSTITUTE FORM PTO-1449 (MODIFIED)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. SSIT-114		SERIAL NO. 10/711,649							
INFORMATION DISCLOSURE STATEMENT BY APPLICANT  (Use several sheets if necessary)  (37 CFR 1.98(b))				APPLICANT Kawamura et al.									
				FILING DATE September 29, 2004		GROUP 1756							
U.S. PATENT DOCUMENTS													
EXAMINER INITIAL		PATENT NUMBER						ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
MDH	O.A	5	6	3	2	8	4	7	05/27/1997	Ohno et al.	156	344	04/24/1995
	O.B	5	6	3	5	4	6	3	06/03/1997	Muraoka	510	175	07/19/1995
	O.C	5	6	3	7	1	5	1	08/10/1997	Schulz	134	2	06/27/1994
	O.D	5	6	4	1	8	8	7	06/24/1997	Beckman et al.	546	26.2	06/24/1997
	O.E	5	6	4	4	8	5	5	07/08/1997	McDermott et al.	34	516	04/06/1995
	O.F	5	6	4	9	8	0	9	07/22/1997	Stapelfeldt	417	63	11/29/1995
	O.G	5	6	5	6	0	9	7	08/12/1997	Olesen et al.	134	1	12/21/1994
	O.H	5	6	6	5	5	2	7	09/09/1997	Allen et al.	430	325	02/03/1997
	O.I	5	6	6	9	2	5	1	09/23/1997	Townsend et al.	68	58	07/30/1996
	O.J	5	6	7	2	2	0	4	09/30/1997	Habuka	117	204	04/25/1996
↓	O.K	5	6	7	6	7	0	5	10/14/1997	Jureller et al.	8	142	03/06/1995
FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS													
		DOCUMENT NUMBER						PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)	
	O.L												
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	O.N												
	O.O												
	O.P												
	O.Q												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDH	O.R	R. Purtell et al., <u>Precision Parts Cleaning Using Supercritical Fluids</u> , J. Vac. Sci. Technol. A., Vol. 11, No. 4, pp. 1696-1701, July 1993.											
↓	O.S	E. Bok et al., <u>Supercritical Fluids for Single Wafer Cleaning</u> , Solid State Technology, pp. 117-120, June 1992											
↓	O.T	T. Adschiri et al., <u>Rapid and Continuous Hydrothermal Crystallization of Metal Oxide Particles in Supercritical Water</u> , J. Am. Ceram. Cos., Vol. 75, No. 4, pp. 1019-1022, 1992.											
EXAMINER <i>Umance D. Adams</i>									DATE CONSIDERED <i>3/3/06</i>				
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EXAMINER INITIAL		PATENT NUMBER							ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
MDH	P.A	5	6	7	9	1	6	9	10/21/1997	Gonzales et al.	134	1.3	12/19/1995
	P.B	5	6	7	9	1	7	1	10/21/1997	Saga et al.	134	3	03/06/1996
	P.C	5	6	8	3	4	7	3	11/04/1997	Jureller et al.	8	142	08/20/1996
	P.D	5	6	8	3	9	7	7	11/04/1997	Jureller et al.	510	286	03/06/1995
	P.E	5	6	8	8	8	7	9	11/18/1997	DeSimone	526	89	02/07/1997
	P.F	5	7	0	0	3	7	9	12/23/1997	Biebl	216	2	02/14/1996
	P.G	5	7	0	2	2	2	8	12/30/1997	Tamal et al.	414	744.5	07/17/1996
	P.H	5	7	0	6	3	1	9	01/06/1998	Holtz	376	203	08/12/1996
	P.I	5	7	1	4	2	9	9	02/03/1998	Combes et al.	430	137	11/04/1996
	P.J	5	7	2	5	9	8	7	03/10/1998	Combes et al.	430	137	11/01/1996
	P.K	5	7	2	6	2	1	1	03/10/1998	Hedrick et al.	521	61	03/21/1996
FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS													
		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)						
	P.L												
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	P.N												
	P.O												
	P.P												
	P.Q												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDH	P.R	B. N. Hansen et al., <u>Supercritical Fluid Transport - Chemical Deposition of Films</u> , Chem. Mater, Vol. 4, No. 4, pp. 749-752, 1992											
	P.S	S. H. Page et al., <u>Predictability and Effect of Phase Behavior of CO<sub>2</sub>/Propylene Carbonate in Supercritical Fluid Chromatography</u> , J. Microcol, Vol. 3, No. 4, pp. 355-369, 1991.											
	P.T	T. Brokamp et al., <u>Synthese und Kristallstruktur Eines Gemischvalenten Lithium-Tantalnitride Li,Ta,N<sub>3</sub></u> , J. Alloys and Compounds, Vol. 176, pp. 47-60, 1991.											
EXAMINER <i>Marice D. Danneberg</i>					DATE CONSIDERED <i>3/3/06</i>								
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EXAMINER INITIAL		PATENT NUMBER			ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE				
MDH	Q.A	5	7	3	0	8	7	4	03/24/1998	Wai et al.	210	638	06/02/1994
	Q.B	5	7	3	6	4	2	5	04/07/1998	Smith et al.	438	778	11/14/1996
	Q.C	5	7	3	9	2	2	3	04/14/1998	DeSimone	526	89	09/18/1995
	Q.D	5	7	4	6	0	0	8	05/05/1998	Yamashita et al.	34	211	02/24/1997
	Q.E	5	7	6	6	3	6	7	06/16/1998	Smith et al.	134	2	05/14/1996
	Q.F	5	7	6	9	5	8	8	06/23/1998	Toshima et al.	414	217	08/20/1996
	Q.G	5	7	8	3	0	8	2	07/21/1998	DeSimone et al.	210	634	11/03/1995
	Q.H	5	7	9	7	7	1	9	08/25/1998	James et al.	417	46	10/30/1996
	Q.I	5	7	9	8	1	2	6	08/25/1998	Fujikawa et al.	425	78	05/21/1997
	Q.J	5	7	9	8	4	3	8	08/25/1998	Sawan et al.	528	483	09/09/1996
✓	Q.K	5	8	0	4	6	0	7	09/08/1998	Hedrick et al.	521	64	10/16/1997
FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS													
		DOCUMENT NUMBER			PUBLICATION DATE		COUNTRY OR PATENT OFFICE		CLASS	SUBCLASS	TRANSLATION (YES/NO)		
	Q.L												
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	Q.N												
	Q.O												
	Q.P												
	Q.Q												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDH	Q.R	B. M. Hybertson et al., <u>Deposition of Palladium Films by a Novel Supercritical Transport Chemical Deposition Process</u> , Mat. Res. Bull., Vol. 26, pp. 1127-1133, 1991.											
	Q.S	D. H. Ziger et al., <u>Compressed Fluid Technology: Application to RIE Developed Resists</u> , AIChE Journal, Vol. 33, No. 10, pp. 1585-1591, October 1987.											
✓	Q.T	D. W. Matson et al., <u>Rapid Expansion of Supercritical Fluid Solutions: Solute Formation of Powders, Thin Films, and Fibers</u> , Ind. Eng. Chem. Res., Vol. 26, No. 11, pp. 2298-2306, 1987.											
EXAMINER <i>Monica D. Hansen</i>							DATE CONSIDERED <i>3/3/00</i>						
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EXAMINER INITIAL		PATENT NUMBER							ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
MDH	R.A.	5	8	0	7	6	0	7	08/15/1998	Smith et al.	427	96	11/14/1996
	R.B.	5	8	1	7	1	7	8	10/06/1998	Mita et al.	118	666	05/29/1996
	R.C.	5	8	4	7	4	4	3	12/08/1998	Cho et al.	257	632	11/14/1996
	R.D.	5	8	6	6	0	0	5	02/02/1999	DeSimone et al.	210	634	11/01/1996
	R.E.	5	8	6	8	8	5	6	02/09/1999	Douglas et al. <sup>4</sup>	134	2	07/23/1997
	R.F.	5	8	6	8	8	6	2	02/09/1999	Douglas et al.	134	26	07/31/1997
	R.G.	5	8	7	2	0	6	1	02/16/1999	Lee et al.	438	705	10/27/1997
	R.H.	5	8	7	2	2	5	7	02/16/1999	Beckman et al.	546	336	04/01/1997
	R.I.	5	8	7	3	9	4	8	02/23/1999	Kim	134	19	06/24/1997
	R.J.	5	8	8	1	5	7	7	03/16/1999	Sauer et al.	68	5	09/09/1996
	R.K.	5	8	8	2	1	6	5	03/16/1999	Maydan et al. <sup>9</sup>	414	217	09/10/1997
FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS													
		DOCUMENT NUMBER							PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)
	R.L.												
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	R.O.												
	R.P.												
	R.Q.												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDH	R.R.	W. K. Tolley et al., <u>Stripping Organics from Metal and Mineral Surfaces Using Supercritical Fluids</u> , Separation Science and Technology, Vol. 22, pp. 1087-1101, 1987.											
	R.S.	<u>Final Report on the Safety Assessment of Propylene Carbonate</u> , J. American College of Toxicology, Vol. 6, No. 1, pp. 23-51, 1987.											
✓	R.T.	<u>Porous Xerogel Films as Ultra-Low Permittivity Dielectrics for ULSI Interconnect Applications</u> , Materials Research Society, pp. 463-469, 1987.											
EXAMINER <i>Monica D. Davis</i>										DATE CONSIDERED <i>3/3/06</i>			
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EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
MDH	S.A	5 8 8 8 0 5 0	03/30/1999	Fitzgerald et al.	417	46	08/25/1998
	S.B	5 8 9 3 7 5 6	04/13/1999	Berman et al.	438	692	08/26/1997
	S.C	5 8 9 6 8 7 0	04/27/1999	Huynh et al.	134	1.3	03/11/1997
	S.D	5 8 9 8 7 2 7	04/27/1999	Fujikawa et al.	373	110	04/28/1997
	S.E	5 9 0 0 1 0 7	05/04/1999	Murphy et al.	156	359	09/11/1996
	S.F	5 9 0 0 3 5 4	05/04/1999	Batchelder	430	395	07/03/1997
	S.G	5 9 0 4 7 3 7	05/18/1999	Preston et al.	8	158	11/26/1997
	S.H	5 9 0 6 8 6 6	05/25/1999	Webb	427	534	02/10/1997
	S.I	5 9 0 8 5 1 0	06/01/1999	McCullough et al.	134	2	10/16/1996
	S.J	5 9 2 8 3 8 9	07/27/1999	Jevtic	29	25.01	10/21/1996
✓	S.K	5 9 3 2 1 0 0	08/03/1999	Yager et al.	210	634	06/14/1996
FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
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	S.O						
	S.P						
	S.Q						
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)							
MDH	S.R	Kawakami et al., <u>A Super Low-k(k=1.1) Silica Aerogel Film Using Supercritical Drying Technique</u> , IEEE, pp. 143-145, 2000.					
↓	S.S	R. F. Reidy, <u>Effects of Supercritical Processing on Ultra Low-k Films</u> , Texas Advanced Technology Program, Texas Instruments and the Texas Academy of Mathematics and Science					
↓	S.T	Anthony Muscat, <u>Backend Processing Using Supercritical CO<sub>2</sub></u> , University of Arizona					
EXAMINER <i>Umair R. Harris</i>				DATE CONSIDERED <i>3/3/06</i>			
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STATEMENT BY APPLICANT

(Use several sheets if necessary)

(37 CFR 1.98(b))

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Kawamura et al.FILING DATE  
September 29, 2004GROUP  
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## U.S. PATENT DOCUMENTS

EXAMINER INITIAL		PATENT NUMBER							ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
MDH	T.A	5	9	3	4	8	5	6	08/10/1999	Asakawa et al.	414	217	04/28/1997
	T.B	5	9	3	4	9	9	1	08/10/1999	Rush	454	187	02/01/1998
	T.C	5	9	4	4	9	9	6	08/31/1999	DeSimone et al.	210	634	05/02/1997
	T.D	5	9	5	5	1	4	0	09/21/1999	Smith et al.	427	96	11/14/1996
	T.E	5	9	6	5	0	2	5	10/12/1999	Wai et al.	210	634	01/21/1998
	T.F	5	9	7	5	4	9	2	11/02/1999	Brenes	251	175	07/14/1997
	T.G	5	9	7	6	2	6	4	11/02/1999	McCullough et al.	134	2	11/30/1998
	T.H	5	9	7	9	3	0	6	11/09/1999	Fujikawa et al.	100	90	03/25/1998
	T.I	5	9	8	0	6	4	8	11/09/1999	Adler	134	34	02/14/1992
	T.J	5	9	8	1	3	9	9	11/09/1999	Kawamura et al.	438	715	02/15/1995
	T.K	5	9	8	9	3	4	2	11/23/1999	Ikede et al.	118	52	01/28/1997

## FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS

		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)
	T.L						
	T.M						
	T.N						
	T.O						
	T.P						
	T.Q						

## OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)

MDH	T.R	D. Goldfarb et al., <u>Aqueous-based Photoresist Drying Using Supercritical Carbon Dioxide to Prevent Pattern Collapse</u> , J. Vacuum Sci. Tech. B, Vol. 18, No. 6, pp. 3313, 2000.					
	T.S	H. Namatsu et al., <u>Supercritical Drying for Water-Rinsed Resist Systems</u> , J. Vacuum Sci. Tech. B, Vol. 18, No. 6, pp. 3308, 2000.					
	T.T	N. Sundararajan et al., <u>Supercritical CO<sub>2</sub> Processing for Submicron Imaging of Fluoropolymers</u> , Chem. Mater., Vol. 12, 41, 2000.					

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Morgan D. Parnis

DATE CONSIDERED

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MDH	U.A	5	9	9	2	6	8	0	11/30/1999	Smith	220	812	01/29/1997
	U.B	5	9	9	4	6	9	6	11/30/1999	Tai et al.	250	288	01/27/1998
	U.C	6	0	0	5	2	2	6	12/21/1999	Aschner et al.	219	390	11/24/1997
	U.D	6	0	1	7	8	2	0	01/25/2000	Ting et al.	438	689	07/17/1998
	U.E	6	0	2	1	7	9	1	02/08/2000	Dryer et al.	134	100.1	06/29/1998
	U.F	6	0	2	4	8	0	1	02/15/2000	Wallace et al.	134	1	12/09/1996
	U.G	6	0	2	9	3	7	1	02/29/2000	Kamikawa et al.	34	516	09/16/1998
	U.H	6	0	3	5	8	7	1	03/14/2000	Eui-Yeol	134	61	03/18/1998
	U.I	6	0	3	7	2	7	7	03/14/2000	Masakara et al.	438	787	11/14/1996
	U.J	6	0	5	3	3	4	8	04/25/2000	Morch	220	263	12/31/1997
✓	U.K	6	0	5	6	0	0	8	05/02/2000	Adams et al.	137	487.5	09/22/1997
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	U.O												
	U.P												
	U.Q												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDH	U.R	Hideaki Itakura et al., <u>Multi-Chamber Dry Etching System</u> , Solid State Technology, pp. 209-214, April 1982											
↓	U.S	Joseph L. Foszez, <u>Diaphragm Pumps Eliminate Seal Problems</u> , Plant Engineering, pp. 1-5, February 1, 1996											
✓	U.T	Bob Agnew, <u>WILDEN Air-Operated Diaphragm Pumps</u> , Process & Industrial Training Technologies, Inc., 1996											
EXAMINER <i>Margaret D. Hanson</i>									DATE CONSIDERED <i>3/3/06</i>				
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MDA	V.A	6	0	6	3	7	1	4	05/18/2000	Smith et al.	438	778	11/14/1996
	V.B	6	0	6	7	7	2	8	05/30/2000	Farmer et al.	34	470	02/13/1998
	V.C	6	0	7	7	0	5	3	06/20/2000	Fujikawa et al.	417	399	04/10/1998
	V.D	6	0	7	7	3	2	1	06/20/2000	Adachi et al.	29	25.01	11/07/1997
	V.E	6	0	8	2	1	5	0	07/04/2000	Stucker	68	18 R	07/30/1999
	V.F	6	0	8	5	9	3	5	07/11/2000	Malchow et al.	220	813	08/10/1998
	V.G	6	0	9	7	0	1	5	08/01/2000	McCullough et al.	219	686	10/14/1998
	V.H	6	0	9	9	6	1	9	08/08/2000	Lansbarkis et al.	95	118	10/13/1998
	V.I	6	1	0	0	1	9	8	08/08/2000	Grieger et al.	438	692	02/27/1998
	V.J	6	1	1	0	2	3	2	08/29/2000	Chen et al.	29	25.01	10/01/1998
	V.K	6	1	1	4	0	4	4	09/05/2000	Houston et al.	428	447	05/30/1997
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	V.L												
	V.M												
	V.N												
	V.O												
	V.P												
	V.Q												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDA	V.R	Nakata, <u>Active Matrix Substrate and Manufacturing Method Thereof</u> , US 2001/0024247 A1, Publication Date 09/27/2001, Filing Date 03/13/2001, U.S. Class 349/43											
	V.S	Biberger et al., <u>Method of Depositing Metal Film and Metal Deposition Cluster Tool Including Supercritical Drying/Cleaning Module</u> , US 2002/0001929 A1, Publication Date 01/03/2002, Filed 04/24/2001, U.S. Class 438/584.											
✓	V.T	DeYoung et al., <u>Methods for Removing Particles from Microelectronic Structures</u> , US 2002/0112746 A1, Publication Date 08/22/2002, Filed 09/13/2001, U.S. Class 134/36											
EXAMINER <i>Unover D. Plam</i>										DATE CONSIDERED <i>3/3/06</i>			
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SUBSTITUTE FORM PTO-1449 (MODIFIED)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. SSIT-114		SERIAL NO. 10/711,649	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT				APPLICANT Kawamura et al.  FILING DATE September 29, 2004 GROUP 1756			
(Use several sheets if necessary)							
(37 CFR 1.98(b))							
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL	PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
MDH	W.A	6 1 2 2 5 6 6	09/19/2000	Nguyen et al.	700	218	03/03/1998
	W.B	6 1 2 8 8 3 0	10/10/2000	Bettcher et al.	34	404	05/15/1999
	W.C	6 1 4 0 2 5 2	10/31/2000	Cho et al.	438	781	05/05/1998
	W.D	6 1 4 5 5 1 9	11/14/2000	Konishi et al.	134	95.2	05/15/1997
	W.E	6 1 4 9 8 2 8	11/21/2000	Vaartstra	216	57	05/05/1997
	W.F	6 1 5 9 2 9 5	12/12/2000	Maskara et al.	118	688	04/22/1999
	W.G	6 1 6 4 2 9 7	12/26/2000	Kamikawa	134	61	06/12/1998
	W.H	6 1 7 1 6 4 5	01/09/2001	Smith et al.	427	96	07/15/1998
	W.I	6 1 8 6 7 2 2	02/13/2001	Shirai	414	217	02/24/1998
	W.J	6 2 0 0 9 4 3	03/13/2001	Romack et al.	510	285	05/27/1999
✓	W.K	6 2 0 3 5 8 2	03/20/2001	Berner et al.	29	25.01	07/15/1996
FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
	DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)	
	W.L						
	W.M						
	W.N						
	W.O						
	W.P						
	W.Q						
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)							
MDH	W.R	Beam, <u>High Purity CO2 and BTEX Recovery</u> , US 2002/0117391 A1, Publication Date 08/29/2002, Filed 01/28/2002, U.S. Class 203/81					
↓	W.S	Chlou, <u>Method of Rinsing Residual Etching Reactants/Products on a Semiconductor Wafer</u> , US 2002/0142595 A1, Publication Date 10/03/2002, Filed 03/29/2001, U.S. Class 438/689					
↓	W.T	Masuda et al., <u>Process and Apparatus for Removing Residues from the Microstructure of an Object</u> , US 2002/0164873 A1, Publication Date 11/07/2002, Filed 02/08/2002, U.S. Class 438/689					
EXAMINER <i>Monica D. Hames</i>				DATE CONSIDERED <i>3/3/06</i>			
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT  (Use several sheets if necessary)				APPLICANT Kawamura et al.									
				FILING DATE September 29, 2004		GROUP 1756							
U.S. PATENT DOCUMENTS													
EXAMINER INITIAL		PATENT NUMBER				ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE			
MDH	X.A	6	2	1	6	3	6	4	04/17/2001	Tanaka et al. *	34	448	04/14/1999
	X.B	6	2	2	4	7	7	4	05/01/2001	DeSimone et al.	210	634	02/12/1999
	X.C	6	2	2	8	5	6	3	05/08/2001	Starov et al.	430	327	09/17/1999
	X.D	6	2	2	8	8	2	6	05/08/2001	DeYoung et al.	510	291	10/18/1999
	X.E	6	2	3	2	2	3	8	05/15/2001	Chang et al.	438	725	02/08/1999
	X.F	6	2	3	2	4	1	7	05/15/2001	Rhodes et al.	526	171	09/12/1997
	X.G	6	2	3	5	6	3	4	05/22/2001	White et al. *	438	680	05/20/1998
	X.H	6	2	3	9	0	3	8	05/29/2001	Wen	438	745	09/09/1996
	X.I	6	2	4	1	8	2	5	06/05/2001	Wytman	118	733	04/16/1999
	X.J	6	2	4	2	1	6	5	06/05/2001	Vaartstra	430	329	08/28/1998
✓	X.K	6	2	4	4	1	2	1	06/12/2001	Hunter	73	865.9	03/06/1998
FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS													
		DOCUMENT NUMBER				PUBLICATION DATE		COUNTRY OR PATENT OFFICE		CLASS	SUBCLASS	TRANSLATION (YES/NO)	
	X.L												
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	X.N												
	X.O												
	X.P												
	X.Q												
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													
MDH	X.R	Cotte et al., <u>Process of Removing Residue Material from a Precision Surface</u> , US 2003/0003762 A1, Publication Date 01/02/2003, Filed 06/27/2001, U.S. Class 438/745											
I	X.S	Chang et al., <u>Method of Avoiding Dielectric Layer Deterioration with a Low Dielectric Constant During a Stripping Process</u> , US 2003/0013311 A1, Publication Date 01/16/2003, Filed 07/03/2001, U.S. Class 438/704											
✓	X.T	Reid et al., <u>Method for Removing a Sacrificial Material with a Compressed Fluid</u> , US 2003/0047533 A1, Publication Date 03/13/2003, Filed 06/10/2002, U.S. Class 216/24											
EXAMINER <i>Michael D. Hamer</i>						DATE CONSIDERED <i>3/3/06</i>							
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT				APPLICANT Kawamura et al.			
(37 CFR 1.98(b)) (Use several sheets if necessary)				FILING DATE September 29, 2004		GROUP 1756	

U.S. PATENT DOCUMENTS									
EXAMINER INITIAL	PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE			
MDH	Y.A. 6 2 5 1 2 5 0	06/26/2001	Keigler	205	89	09/03/1999			
	Y.B. 6 2 5 5 7 3 2	07/03/2001	Yokoyama et al.	257	760	08/03/1999			
	Y.C. 6 2 7 0 5 3 1	08/07/2001	DeYoung et al.	8	142	08/28/1998			
	Y.D. 5 2 7 0 9 4 8	08/07/2001	Sato et al.	430	314	06/07/1999			
	Y.E. 6 2 7 7 7 5 3	08/21/2001	Mullee et al.	438	692	09/28/1999			
	Y.F. 6 2 8 4 5 5 8	09/04/2001	Sakamoto	438	30	11/25/1998			
	Y.G. 6 2 8 6 2 3 1	09/11/2001	Bergman et al.	34	410	01/12/2000			
	Y.H. 6 3 0 5 6 7 7	10/23/2001	Lenz	269	13	03/30/1999			
	Y.I. 6 3 0 6 5 6 4	10/23/2001	Mullee	430	329	05/27/1998			
	Y.J. 6 3 1 9 8 5 8	11/20/2001	Lee et al.	438	787	07/11/2000			
↓	Y.K. 6 3 3 1 4 8 7	12/18/2001	Koch	438	692	02/27/2001			

FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)		
Y.L.							
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Y.O.							
Y.P.							
Y.Q.							

OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)	
MDH	Y.R. Masuda et al., <u>Process and Apparatus for Removing Residues from the Microstructure of an Object</u> , US 2003/0106573 A1, Publication Date 06/12/2003, Filed 02/08/2002, U.S. Class 134/26
	Y.S. Xu et al., <u>Supercritical Fluid Cleaning of Semiconductor Substrates</u> , US 2003/0125225 A1, Publication Date 07/03/2003, Filed 11/25/2002, U.S. Class 510/175
↓	Y.T. Jackson, <u>Dense Fluid Cleaning Centrifugal Phase Shifting Separation Process and Apparatus</u> , US 2003/0205510 A1, Publication Date 11/06/2003, Filed 03/13/2001, U.S. Class 210/86.

EXAMINER <i>Monica D. Hannas</i>	DATE CONSIDERED <i>3/3/06</i>
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT  (Use several sheets if necessary)  (37 CFR 1.98(b))				APPLICANT Kawamura et al.			
				FILING DATE September 29, 2004		GROUP 1756	

U.S. PATENT DOCUMENTS														
EXAMINER INITIAL		PATENT NUMBER								ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
MDH	Z.A	6	3	3	4	2	6	6	01/01/2002	Moritz et al.	34	337	09/20/2000	
	Z.B	6	3	4	4	1	7	4	02/05/2002	Miller et al.	422	98	04/12/1999	
	Z.C	6	3	4	4	2	4	3	02/05/2002	McClain et al.	427	388.1	08/02/2001	
	Z.D	6	3	5	5	0	7	2	03/12/2002	Racette et al.	8	142	10/15/1999	
	Z.E	6	3	5	8	6	7	3	03/19/2002	Namatsu	430	311	09/03/1999	
	Z.F	6	3	6	1	6	9	6	03/26/2002	Spiegelman et al.	210	662	01/19/2000	
	Z.G	6	3	6	7	4	9	1	04/09/2002	Marshall et al.	134	104.4	09/15/2000	
	Z.H	6	3	8	0	1	0	5	04/30/2002	Smith et al.	438	778	06/02/1999	
	Z.I	6	3	8	8	3	1	7	05/14/2002	Reese	257	713	09/25/2000	
	Z.J	6	3	8	9	6	7	7	05/21/2002	Lenz	29	559	08/30/2001	
↓	Z.K	6	4	1	8	9	5	6	07/16/2002	Bloom	137	14	11/15/2000	

FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)
	Z.L						
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	Z.P						
	Z.Q						

OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)		
MDH	Z.R	Masuda et al., <u>Process and Composition for Removing Residues from the Microstructure of an Object</u> , US 2003/0217764 A1, Publication Date 11/27/2003, Filed 05/23/2002, U.S. Class 134/26
	Z.S	DeYoung et al., <u>Methods for Transferring Supercritical Fluids in Microelectronic and Other Industrial Processes</u> , US 2004/0020518 A1, Publication Date 02/05/2004, Filed 05/30/2003, U.S. Class 134/30.
↓	Z.T	Korzenski et al., <u>Supercritical Carbon Dioxide/Chemical Formulation for Removal of Photoresists</u> , US 2004/0087457 A1, Publication Date 05/06/2004, Filed 10/31/2002, U.S. Class 510/177

EXAMINER  <i>Yonguo D. Pan</i>	DATE CONSIDERED  <i>3/3/06</i>
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(37 CFR 1.98(b))				FILING DATE September 29, 2004		GROUP 1756	

U.S. PATENT DOCUMENTS													
EXAMINER INITIAL		PATENT NUMBER							ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
MDH	AA.A	6	4	2	5	9	5	6	07/30/2002	Cotte et al.	134	3	01/05/2001
	AA.B	6	4	3	6	8	2	4	08/20/2002	Chooi et al.	438	687	07/02/1999
	AA.C	6	4	5	1	5	1	0	09/17/2002	Messlick et al.	430	311	02/21/2001
	AA.D	6	4	5	4	5	1	9	09/24/2002	Toshima et al.	414	805	03/07/1997
	AA.E	6	4	5	4	9	4	5	09/24/2002	Weigl et al.	210	634	11/01/2000
	AA.F	6	4	5	4	9	4	5	09/24/2002	Weigl et al.	210	634	11/01/2000
	AA.G	6	4	5	8	4	9	4	10/01/2002	Song et al.	430	5	04/27/2000
	AA.H	6	4	6	1	9	6	7	10/08/2002	Wu et al.	438	705	07/16/2002
	AA.I	6	4	6	4	7	9	0	10/15/2002	Sherstinsky et al.	118	715	03/17/2000
	AA.J	6	4	7	2	3	3	4	10/29/2002	Ikakura et al.	438	778	04/03/2001
✓	AA.K	6	4	7	9	4	0	7	11/12/2002	Yokoyama et al.	438	788	01/23/2001

FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)
	AA.L						
	AA.M						
	AA.N						
	AA.O						
	AA.P						
	AA.Q						

OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)	
MDH	AA.R Inoue et al., <u>Method of High Pressure Treatment</u> , US 2004/0103922 A1, Publication Date 06/03/2004, Filed 11/21/2002, U.S. Class 134/26
↓	AA.S Schilling, <u>Fluoride in Supercritical Fluid for Photoresist and Residue Removal</u> , US 2004/0112409 A1, Publication Date 06/17/2004, Filed 12/16/2002, U.S. Class 134/26
↓	AA.T Schilling, <u>Tetra-Organic Ammonium Fluoride and HF in Supercritical Fluid for Photoresist and Residue Removal</u> , US 2004/0177867 A1, Publication Date 09/16/2004, Filed 05/20/2003, U.S. Class 134/26

EXAMINER  Ummonio. Hansen	DATE CONSIDERED  3/3/06
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PATENT AND TRADEMARK OFFICEATTY. DOCKET NO.  
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10/711,649INFORMATION DISCLOSURE  
STATEMENT BY APPLICANT

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Kawamura et al.FILING DATE  
September 29, 2004GROUP  
1756

## U.S. PATENT DOCUMENTS

EXAMINER INITIAL		PATENT NUMBER							ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
MDL	BB.A	6	5	5	4	5	0	7	04/29/2003	Namatsu	396	611	12/20/2001
	BB.B	6	5	5	8	4	7	5	05/06/2003	Jur et al.	134	21	04/10/2000
	BB.C	6	5	6	1	2	1	3	05/13/2003	Wang et al.	137	263	06/05/2001
	BB.D	6	5	6	1	2	2	0	05/13/2003	McCullough et al.	137	565.12	04/23/2001
	BB.E	6	5	6	1	4	8	1	05/13/2003	Filonczuk	251	129.12	08/13/2001
	BB.F	6	5	6	1	7	6	7	05/13/2003	Berger et al.	417	53	08/01/2001
	BB.G	6	5	6	2	1	4	6	05/13/2003	DeYoung et al.	134	30	08/17/2001
	BB.H	6	5	6	4	8	2	6	05/20/2003	Shen	137	505.18	07/24/2001
	BB.I	6	5	7	6	1	3	8	06/10/2003	Sateria et al.	210	664	12/14/2000
	BB.J	6	5	8	3	0	6	7	06/24/2003	Chang et al.	438	723	07/03/2001
✓	BB.K	6	6	2	3	3	5	5	09/23/2003	McClain et al.	457	60	03/23/2001

## FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS

		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)
	BB.L						
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## OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)

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*Umapada D. Harman*

DATE CONSIDERED

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FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)
MDH	A.L	CN 1399790 A	02/26/2003	China	H01L	21/00	Abstract Only
	A.M	DE 36 08 783 A1	09/17/1987	Germany	C30B	25/12	Abstract Only
	A.N	DE 39 04 514 C2	03/23/1990	Germany	D06L	1/00	Abstract Only
	A.O	DE 39 06 724 C2	09/13/1990	Germany	D06P	1/90	Abstract Only
	A.P	DE 39 06 735 C2	09/06/1990	Germany	D06L	3/00	Abstract Only
✓	A.Q	DE 39 06 737 A1	09/13/1990	Germany	D06M	11/59	Abstract Only

OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)		
	A.R	
	A.S	
	A.T	

EXAMINER <i>Manfred D. Hansen</i>	DATE CONSIDERED 3/3/06
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT  (Use several sheets if necessary)  (37 CFR 1.98(b))				APPLICANT Kawamura, et al.			
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U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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	B.J						
	B.K						
FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)
MN+	B.L	DE 40 04 111 C2	08/23/1990	Germany	D06L	1/00	Abstract Only
	B.M	DE 43 44 021 A1	06/29/1995	Germany	D06P	1/16	Abstract Only
	B.N	DE 44 29 470 A1	03/02/1995	Germany	D06P	5/04	Abstract Only
	B.O	DE 198 60 084 A1	07/06/2000	Germany	H01L	21/3213	Abstract Only
	B.P	EP 0 244 951 A2	11/11/1987	EPO	H01L	21/00	
✓	B.Q	EP 02 72 141 A2	06/22/1988	EPO	H01L	21/00	
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)							
	B.R						
	B.S						
	B.T						
EXAMINER <i>Michael D. Hamer</i>				DATE CONSIDERED <i>3/3/06</i>			
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U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)
MDEH	C.L	EP 0 283 740 A2	09/28/1988	EPO	C22B	3/00	
	C.M	EP 0 302 345 A2	02/08/1989	EPO	C22B	3/00	Abstract Only
	C.N	EP 0 370 233 A1	05/30/1990	EPO	C22B	3/00	Abstract Only
	C.O	EP 0 391 035 A2	10/10/1990	EPO	C23G	5/00	
	C.P	EP 0 453 867 A1	10/30/1991	EPO	F16K	51/02	
↓	C.Q	EP 0 518 653 B1	12/16/1992	EPO	D06L	1/02	
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)							
	C.R						
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EXAMINER <i>Umpei D. Hansen</i>				DATE CONSIDERED <i>3/3/06</i>			
EXAMINER: Initial if citation considered, whether or not in conformance. Draw line through citation only if not in conformance and not considered. Include a copy of this form with next communication to Applicant.							

SUBSTITUTE FORM PTO-1449 (MODIFIED)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. SSIT-114		SERIAL NO. 10/711,649	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT  (Use several sheets if necessary)  (37 CFR 1.98(b))				APPLICANT Kawamura et al.			
				FILING DATE September 29, 2004		GROUP 1756	
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	D.A						
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FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)
MDH	D.L	EP 0 536 752 A2	04/14/1993	EPO	C11D	3/20	
	D.M	EP 0 572 913 A1	12/08/1993	EPO	B01D	11/02	
	D.N	EP 0 587 168 A1	03/16/1994	EPO	B08B	7/00	Abstract Only
	D.O	EP 0 620 270 A3	10/19/1994	EPO	C11D	7/50	
	D.P	EP 0 679 753 B1	11/02/1995	EPO	D06F	43/00	
✓	D.Q	EP 0 711 864 B1	05/15/1996	EPO	D06G	1/00	
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)							
	D.R						
	D.S						
	D.T						
EXAMINER <i>Michael D. Hansen</i>				DATE CONSIDERED <i>3/3/06</i>			
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT  (Use several sheets if necessary)				APPLICANT Kawamura et al.			
				FILING DATE September 29, 2004		GROUP 1756	
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)
	MDH	EP 0 726 099 A2	08/14/1996	EPO	B08B	5/00	
		EP 0 727 711 A2	08/21/1996	EPO	G03F	7/004	Abstract Only
		EP 0 822 583 A2	02/04/1998	EPO	H01L	21/306	
		EP 0 829 312 A2	03/18/1998	EPO	B08B	3/08	
		EP 0 836 895 A2	04/22/1998	EPO	B08B	7/00	
	✓	EP 0 903 775 A2	03/24/1999	EPO	H01L	21/00	
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)							
	E.R						
	E.S						
	E.T						
EXAMINER <i>Ungar O. Hansen</i>				DATE CONSIDERED <i>3/3/06</i>			
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SUBSTITUTE FORM PTO-1449 (MODIFIED)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. SSIT-114		SERIAL NO. 10/711,649	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT  (Use several sheets if necessary)				APPLICANT Kawamura et al.			
(37 CFR 1.98(b))				FILING DATE September 29, 2004		GROUP 1756	
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)
MDL	F.L	FR 1 499 491	09/18/1967	France	F16K		No
	F.M	GB 2 003 975	03/21/1979	Great Britain	F04B	43/06	
	F.N	GB 2 193 482	02/10/1988	Great Britain	B25J	18/02	
	F.O	JP 1-045131	02/17/1989	Japan	B01D	011/04	Abstract Only
	F.P	JP 1-246835	10/02/1989	Japan	H01L	21/304	Abstract Only
↓	F.Q	JP 2-148841	06/07/1990	Japan	H01L	21/306	Abstract Only
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)							
	F.R						
	F.S						
	F.T						
EXAMINER <i>Manuel D. Hansen</i>				DATE CONSIDERED <i>3/3/06</i>			
EXAMINER: Initial if citation considered, whether or not in conformance. Draw line through citation only if not in conformance and not considered. Include a copy of this form with next communication to Applicant.							

SUBSTITUTE FORM PTO-1449 (MODIFIED)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. SSIT-114		SERIAL NO. 10/711,649	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT  (Use several sheets if necessary)  (37 CFR 1.98(b))				APPLICANT Kawamura et al.			
				FILING DATE September 29, 2004		GROUP 1756	
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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Mdt	G.L	JP 2-209729	08/21/1990	Japan	H01L	21/302	Abstract Only
	G.M	JP 2-304941	12/18/1990	Japan	H01L	21/56	Abstract Only
	G.N	JP 7-142333	06/02/1995	Japan	H01L	021/027	Abstract Only
	G.O	JP 8-186140 A	07/16/1996	Japan	H01L	21/56	Abstract Only
	G.P	JP 8-222508 A	08/30/1996	Japan	H01L	021/027	Abstract Only
✓	G.Q	JP 10-144757 A	05/29/1998	Japan	H01L	21/68	Abstract Only
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)							
	G.R						
	G.S						
	G.T						
EXAMINER <i>Monica D. Hansen</i>				DATE CONSIDERED <i>3/3/06</i>			
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SUBSTITUTE FORM PTO-1449 (MODIFIED)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. SSIT-114		SERIAL NO. 10/711,649	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT  (Use several sheets if necessary)				APPLICANT Kawamura et al.			
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EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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Mdt	H.L	JP 10335408 A	12/18/1998	Japan	H01L	21/56	Yes
	H.M	JP 11-200035	07/27/1999	Japan	C23C	14/34	Abstract Only
	H.N	JP 56-142629	11/07/1998	Japan	H01L	21/205	Abstract Only
	H.O	JP 60-192333	09/30/1985	Japan	H01L	21/30	Abstract Only
	H.P	JP 60-2348479	11/27/1985	Japan	C23C	14/56	Abstract Only
V	H.Q	JP 60-246635	12/06/1985	Japan	H01L	21/302	Abstract Only
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)							
	H.R						
	H.S						
	H.T						
EXAMINER <i>Monica D. Davis</i>				DATE CONSIDERED <i>3/3/06</i>			
EXAMINER: Initial if citation considered, whether or not in conformance. Draw line through citation only if not in conformance and not considered. Include a copy of this form with next communication to Applicant.							

SUBSTITUTE FORM PTO-1449 (MODIFIED)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. SSIT-114		SERIAL NO. 10/711,649	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT  (Use several sheets if necessary)				APPLICANT Kawamura et al.			
				FILING DATE September 29, 2004		GROUP 1756	
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)
MDX-1	I.L	JP 61-017151	01/25/1986	Japan	G03G	5/082	Abstract Only
↓	I.M	JP 61-231166	10/15/1986	Japan	C23C	14/24	Abstract Only
	I.N	JP 62-125619	06/06/1987	Japan	H01L	21/30	Abstract Only
	I.O	JP 63-303059	12/09/1988	Japan	C23C	14/22	Abstract Only
	I.P	JP 2000-106358	04/11/2000	Japan	H01L	21/3065	Yes
	I.Q	SE 251213	08/16/1948	Switzerland	100a		No
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)							
	I.R						
	I.S						
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EXAMINER <i>Ungeneid D. Harrison</i>				DATE CONSIDERED <i>3/3/06</i>			
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT  (Use several sheets if necessary)				APPLICANT Kawamura et al.			
				FILING DATE September 29, 2004		GROUP 1756	
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY OR PATENT OFFICE	CLASS	SUBCLASS	TRANSLATION (YES/NO)
MDT	J.L	WO 87/07309	12/03/1987	PCT	C23C	16/00	
	J.M	WO 90/06189	06/14/1990	PCT	B08B	7/00	
	J.N	WO 90/13675	11/15/1990	PCT	C22B	3/00	Abstract Only
	J.O	WO 91/12629 A	08/22/1991	PCT	H01L	21/00	
	J.P	WO 93/14255	07/22/1993	PCT	D06B	5/16	Abstract Only
✓	J.Q	WO 93/14259	07/22/1993	PCT	D06M	11/76	Abstract Only
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)							
	J.R						
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	J.T						
EXAMINER <i>Monica D. Harris</i>				DATE CONSIDERED <i>3/3/06</i>			
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				FILING DATE September 29, 2004		GROUP 1756	
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
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MDI	K.L	WO 93/20116	10/14/1993	PCT	C08F	14/18	
	K.M	WO 96/277704	09/12/1996	PCT	D06L	1/00	
	K.N	WO 99/18603 A	04/15/1999	PCT	H01L	21/00	
	K.O	WO 99/49998	10/07/1999	PCT	B08B	5/00	
	K.P	WO 00/36635	06/22/2000	PCT	H01L	21/00	
V	K.Q	WO 00/73241 A1	12/07/2000	PCT	C04B	35/622	
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)							
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EXAMINER <i>Monica P. Harris</i>				DATE CONSIDERED <i>3/3/06</i>			
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SUBSTITUTE FORM PTO-1449 (MODIFIED)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. SSIT-114		SERIAL NO. 10/711,649	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT  (Use several sheets if necessary)				APPLICANT Kawamura et al.			
				FILING DATE September 29, 2004		GROUP 1756	
U.S. PATENT DOCUMENTS							
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FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
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MDH	LL	WO 01/10733 A1	02/15/2001	PCT	B65D	55/00	
	LM	WO 01/33613 A2	05/10/2001	PCT	H01L	21/00	
	LN	WO 01/33615 A3	05/10/2001	PCT	H01L	21/00	
	LO	WO 01/55628 A1	08/02/2001	PCT	F16K	51/02	
	LP	WO 01/68279 A2	09/20/2001	PCT	B08B	7/00	
	LQ	WO 01/74538 A1	10/11/2001	PCT	B24C	1/00	
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)							
	L.R						
	L.S						
	L.T						
EXAMINER <i>Unpublished</i>				DATE CONSIDERED <i>3/3/06</i>			
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT  (Use several sheets if necessary)  (37 CFR 1.98(b))				APPLICANT Kawamura et al.			
				FILING DATE September 29, 2004		GROUP 1756	

U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS							
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MDL	M.L	WO 01/78911 A1	10/25/2001	PCT	B08B	3/00	
	M.M	WO 01/85391 A2	11/15/2001	PCT	B24B		
	M.N	WO 01/94782 A2	12/13/2001	PCT	F04	43/02	
	M.O	WO 02/09894 A2	02/07/2002	PCT	B08B		
	M.P	WO 02/11191 A2	02/07/2002	PCT	H01L	21/00	
↓	M.Q	WO 02/16051 A2	02/28/2002	PCT	B05D		

OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)	
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	M.S
	M.T

EXAMINER <i>Monica D. Harris</i>	DATE CONSIDERED <i>3/3/06</i>
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SUBSTITUTE FORM PTO-1449 (MODIFIED)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. SSIT-114		SERIAL NO. 10/711,649	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT  (Use several sheets if necessary)				APPLICANT Kawamura et al.			
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U.S. PATENT DOCUMENTS							
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MDH	N.L	WO 03/030219 A2	10/04/2003	PCT	H01L		
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EXAMINER <i>Umaria D. Harrison</i>				DATE CONSIDERED <i>3/3/06</i>			
EXAMINER: Initial if citation considered, whether or not in conformance. Draw line through citation only if not in conformance <u>and</u> not considered. Include a copy of this form with next communication to Applicant.							

5/27/05

# ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

## Title of Invention

## A METHOD FOR SUPERCRITICAL CARBON DIOXIDE PROCESSING OF FLUORO-CARBON FILMS

Application Number : 10/711649



Confirmation Number: 5648

First Named Applicant: Kohei Kawamura

Attorney Docket Number: SSIT-114

Art Unit: 1756

Examiner:

Search string: ( 6485895 or 6486078 or 6492090 or 6500605 or 6508259 or 6509136 or 6521466 or 6537916 or 6541278 or 6546946 or 6550484 or 6635582 or 6641678 or 6656666 or 6669916 or 6673521 or 6677244 or 6685903 or 6737725 or 6764552 or 6777312 or 6780765 ).pn

## US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
MDT	1	6485895	2002-11-26	Choi et al.	B1	430	330
	2	6486078	2002-11-26	Rangarajan et al.	B1	438	778
	3	6492090	2002-12-10	Nishi et al.	B2	430	270.1
	4	6500605	2002-12-31	Mullee et al.	B1	430	329
	5	6508259	2003-01-21	Tseronis et al.	B1	134	105
	6	6509136	2003-01-21	Goldfarb et al.	B1	430	272.1
	7	6521466	2003-02-18	Castrucci	B1	438	5
	8	6537916	2003-03-25	Mullee et al.	B2	438	692
	9	6541278	2003-04-01	Morita et al.	B2	438	3
	10	6546946	2003-04-15	Dunmire	B2	137	15.18
	11	6550484	2003-04-22	Gopjnath et al.	B1	134	1.2
	12	6635582	2003-10-21	Yun et al.	B2	438	745
	13	6641678	2003-11-04	DeYoung et al.	B2	134	36
	14	6656666	2003-12-02	Simons et al.	B2	430	322
	15	6669916	2003-12-30	Heim et al.	B2	423	245.1
	16	6673521	2004-01-06	Moreau et al.	B2	430	315
	17	6677244	2004-01-13	Ono et al.	B2	438	706
	18	6685903	2004-02-03	Wong et al.	B2	423	262
	19	6737725	2004-05-18	Grill et al.	B2	257	522
	20	6764552	2004-07-20	Joyce et al.	B1	134	3
V	21	6777312	2004-08-17	Yang et al.	B2	438	464

22	6780765	2004-08-24	Goldstein	B2	438	660
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## Remarks

Note: Remarks are not for responding to an office action.

In accordance with the duty of candor and good faith imposed by 37 CFR 1.56 and means of complying therewith according to 37 CFR 1.97 and 1.98, the references listed in this Supplemental Information Disclosure Statement are called to the attention of the United States Patent and Trademark Office in connection with the above-identified patent application. No admission is made that the cited art represents the prior art or that the cited art is the most material art. In accordance with 37 CFR 1.97(b), this Supplemental Information Disclosure Statement shall be considered because it is filed before the mailing date of a first Office Action on the merits. The Examiner is urged to consider all the cited references and to make an independent decision with respect to their materiality. Applicants believe no fee is due in connection with the filing of this paper. If any additional fees are necessary to complete this communication, please apply them to Deposit Account No. 23-3000.

## Signature

Examiner Name	Date
<i>Michael D. Kamm</i>	3/3/06